

A DEPOSITION SENSOR BASED ON DIFFERENTIAL HEAT FLUX MEASUREMENT

FIELD OF INVENTION

[0001] The invention pertains generally to the monitoring of mineral and biofilm deposition in industrial fluid processing vessels and in particular relates to a method and apparatus for the early detection and measurement of deposit accumulation.

BACKGROUND OF THE INVENTION

[0002] Chemical and/or biological deposition in industrial process fluid adversely affects processing efficiency and can force operational downtime or even plant shutdown. It is well known in the art that mineral and/or biofilm deposition in cooling towers, heat exchangers, or other fluid processing vessels reduces critical heat transfer efficiency, decreases flow velocity, and can lead to structure fatigue and crack formation. Moreover, the maintenance of service water heat exchanger performance is a safety issue for utility plants, especially nuclear power plants. Quite obviously then, there is a need to provide for the accurate and timely detection and measurement of chemical and/or biological deposit accumulation in industrial process fluid and processing vessels.

[0003] Traditionally, the onset of deposition in industrial process fluid has been monitored by measuring either the temperature difference across a heat transfer surface or by measuring physical and chemical changes caused by deposition on a clean surface immersed in the fluid by way of electrochemical, optical, spectroscopic, or acoustic methods. Several monitoring systems based on temperature measurement have been used to monitor mineral and biofilm deposition, especially in cooling towers and heat exchangers. The heat transfer surface in many of these systems is simulated by electric heat. These systems are usually easy to set up and operate. They provide heat transfer resistance values for the simulated heat transfer surface, which can be correlated to the overall heat

transfer efficiency of heat exchangers. However, deposit monitoring based on temperature measurement is subject to process variations such as changes in process temperature, flow velocity, and environmental temperature. Additionally changes in power supply to the electric heater in a side stream heat flux simulator can cause similar errors. This is why commercially available deposit monitoring systems lack the sensitivity required to detect the early onset of deposit accumulation. Consequently, detecting the early onset of deposit accumulation in a cost effective manner has been heretofore difficult to achieve.

[0004] Methods used to measure the physical and chemical changes caused by deposition include optical transmittance, fluorescence, and quartz crystal microbalance. The sensitivity of these methods is usually high. However, these methods require relatively expensive instruments. Variations and process parameters affect the measurements, and a heat transfer surface may not be easily incorporated.

[0005] The foregoing has outlined a need for an improved system for the monitoring and measurement of deposit accumulation in industrial process fluids and fluid transport vessels. It is therefore desirable to have a fast, accurate, and cost-effective system that is capable of detecting and measuring the early onset of chemical and/or biological deposition.

SUMMARY OF THE INVENTION

[0006] The present invention provides an apparatus and method wherein differential heat flux measurements are used to detect the early onset of deposit accumulation in fluid processing vessels. In this system, a clean heat transfer surface is used as a reference heat transfer path, thereby allowing the differential heat flux measurement. The differential heat flux is used to measure changes in heat transfer resistance across a heat transfer surface. In this way, differential heat flux measurements are used to indicate the early onset of deposition and to quantify the deposition accumulation.

[0007] The invention will be described further in conjunction with the attached drawings and following detailed description.

BRIEF DESCRIPTION OF THE DRAWINGS

[0008] Fig. 1 is a perspective view of a deposition sensor system according to an embodiment of the present invention.

[0009] Fig. 2 is a top view of a deposition sensor system according to an embodiment of the present invention.

[0010] Fig. 3 is an example of temperatures and differential heat flux during CaCO_3 accumulation.

[0011] Fig. 4 is an example of temperatures and differential heat flux during CaCO_3 removal.

[0012] Fig. 5 is a schematic view of a model heat exchanger system used to evaluate the method and apparatus of the present invention.

[0013] Fig. 6 is a trend comparison with U coefficient obtained from the temperature measurement.

[0014] Fig. 7 is an example of differential heat flux and temperature changes relative to their baseline standard deviations.

DETAILED DESCRIPTION

[0015] In accordance with the present invention, it has been discovered that differential heat flux is significantly more sensitive to changes in heat transfer characteristics than traditional approaches based primarily on temperature

measurements. The concept of the present invention is derived from the fact that measuring a small differential change in temperature is much more difficult than directly measuring differential changes in heat flux due to a change in heat transfer resistance. Changes in heat transfer resistance occur when deposits begin to accumulate inside the fluid or vessel under inspection. Since deposit accumulation leads to a change in the heat transfer resistance of the pertinent heat transfer surface, it is possible to detect the onset of deposit accumulation by measuring differential changes in heat flux that occur between the respective heat transfer surfaces. Accordingly, instead of measuring or inferring the temperature difference across a fouling surface as in traditional methods, the present invention involves measurement of differential heat flux between a reference surface and a fouling surface in order to detect and quantify deposit accumulation at such fouling surface.

[0016] With reference now to the drawings, Fig. 1 shows a basic deposition sensor in accordance with an embodiment of the invention. The system generally comprises a pair of hollow vessels 1, a pair of heat flux sensors 2, a mounting unit 3, and a cartridge heater 4 as best shown in Fig. 1. By way of example, and not by way of limitation, the mounting unit 3 was made of a 2.5-inch diameter aluminum bar stock, machined down to 1-inch diameter on one end. Referring again to Fig. 1, a hole was drilled on the smaller end to accept the cartridge heater. The larger end of the aluminum block has two diametrically opposed, 0.805-inch diameter cutouts 1A.

[0017] As best shown in Fig. 2, both vessels 1 comprise a stainless steel tube (20-inch long, 0.75-inch outside diameter, and 0.675-inch inside diameter). Each vessel is conductively mounted onto the mounting unit 3 by way of the respective cutouts 1A. The vessels are fastened in place by metal strip clamps (not shown). The exemplary illustration in Fig. 2 shows that each heat flux sensor 2 is mounted between an outside wall of the vessel and the respective cutout 1A. Accordingly, the present embodiment provides a pair of heat transfer surfaces 51 and 52 that are in thermal communication with heat transfer path 50. A heat

conducting epoxy resin (not shown) was applied to both sides of the heat flux sensors, and the whole sensor assembly was insulated with commercially available insulating materials (not shown) to minimize heat loss. Skilled artisans will appreciate that many variations of the above sensor design are possible to achieve the same results. In this regard, it is contemplated that the heat flux sensors may be mounted to a variety of different shapes or surfaces, for example flat surfaces.

[0018] Referring again to Fig. 1, the two heat flux sensors 2 were purchased from Omega Engineering Inc. The sensors generate an electrical signal indicative of changes in heat flux measured at the heat transfer surfaces 51, 52. The sensors can be connected via wire 8 to a signal processing unit 10 and display unit 12, as shown in Fig. 1 to process and display the corresponding electrical signal generated by the sensors 2. As skilled artisans will appreciate, there are many alternative means, such as a computer based data acquisition system or a standard laboratory voltmeter that could be used to track and display the differential heat flux signal. For example, the electrical signal generated by the heat flux sensors can be transmitted to a microprocessor or other processor means that is effective to continuously calculate, record, and display the differential heat flux.

[0019] It is important to note that many variations in the above mentioned sensor design are possible to meet specific and varied customer needs. For example, design variations which are currently under investigation include: (1) different methods to introduce a heat transfer surface; (2) different methods to maintain a clean reference heat transfer surface; and (3) different geometric arrangements of the whole sensor assembly. Moreover, the heat source that could be used to introduce a heat transfer surface includes: (1) electric heat; (2) sonic or electromagnetic radiation heat (for example, laser induced); and (3) heat carrying process fluids. Methods to generate a clean (reference) heat transfer surface include: (1) addition of a non-fouling fluid or solution containing acids or chemicals that can prevent biofouling or mineral deposition; (2) addition of a synthetic cooling solution that is well known to remain stable during heating

operations; (3) generation of acids or oxidizing reagents with electrochemical cells; (4) introducing sonic or ultrasonic waves toward the reference surface in order to prevent and clean deposition formation; and (5) utilize automated brushing or other mechanical means such as flow excursion to clean away deposition inside the process tube. Another method contemplated by the present invention for generating a clean heat transfer surface includes the introduction of a small fraction (for example 1 ppm) of anti-fouling chemicals into the processing fluid exiting from the fouling tube. In this case, a small fraction of anti-fouling chemicals in combination with the processing fluid exiting from the fouling tube is effective to eliminate the accumulation of deposition without significantly changing flow rate, fluid temperature, or other processing parameters. Accordingly, such resulting non-fouling fluid may subsequently be utilized to generate a clean heat transfer surface.

[0020] Skilled artisans will appreciate that many variations in the above mentioned sensor designs are possible to meet specific and varied customer needs. For instance, the exemplary design described above covers variations in cleaning techniques that may be required to maintain a clean reference cell, but similarly, a clean reference cell can be provided by an electronic signal generated by a circuit that mimics a reference cell. Additionally, an electronic circuit can be designed that controls the heat transfer rate across the reference side by producing a constant heat loss, or that controls the reference side so that the total heat loss across the sensor assembly remains constant. Accordingly, it is not necessary to clean or dissolve deposition from the fluid vessel in order to achieve a guaranteed clean reference surface. A non-limiting example of this would be a finned array that provides constant heat loss across the reference sensor.

[0021] In operation, the fluid under investigation, such as the cooling water, flows through one of the hollow vessels, referred to as the fouling side. A reference fluid with a temperature close to that of the stream on the fouling side flows through the other hollow vessel, referred to as the reference side. The reference fluid required for this sensor could be the heat carrying process fluid or

any non-fouling fluids recirculated by a temperature-controlled bath, or other means capable of achieving a reference heat transfer surface. In the best mode of operation contemplated at the time of invention, the reference stream corresponds to the cooling water stream from the fouling side of the sensor, except the chemical composition is slightly modified by online addition or generation of acids or any chemicals that prevent deposit formation on the reference side of the heat transfer surface. Here, a temperature bath is used to circulate deionized water through the reference tube.

[0022] In order to obtain a constant total heat flux in the system, voltage supplied to the cartridge heater 4 was adjusted to achieve a constant total input at the heat transfer path 50. Since no deposition is expected to occur on the reference side, the present system provides a clean reference surface which can be used to indicate changes in heat flux occurring at the fouling surface, thereby allowing differential heat flux measurement between the reference surface and the fouling surface to indicate the onset of deposition at the fouling surface.

[0023] The present sensor device was evaluated in a laboratory heat exchanger simulator shown in figure 5. The laboratory simulator utilizes a single pass shell and tube exchanger in a manner known in the art. The cooling water is on the shell side. The heat rejection is accomplished through a coil attached to a chiller. The process water (tube side) is heated by a 3kW heater. The recirculating flow was split so that the two measurement systems used identical water. The test was started with deionized water in the system. Hard water was added so that the water hardness gradually increased to concentrations where deposition is more likely. The test conditions are summarized in table 1 below. Cooling water and process water temperatures (inlet and outlet) were measured with four thermistors. The heat transfer coefficient of this model cooling system was obtained from the four temperatures and of the cooling water and process water flow rates according to the standard method known in the art

Table 1: Test Conditions

Inlet Cooling water temperature	120.0 °F
Inlet Process water temperature	140.0 °F
Cooling water flow rate	4.1 gpm
Process water flow rate	1.75 gpm
Contaminant feeding rates	CaCl ₂ : 10 ml/min Carbonate: 10 ml/min
CaCl ₂ concentration	1200 ppm as CaCO ₃
Carbonate	Na ₂ CO ₃ : 150 ppm
Re-circulation bath temperature	120.2 °F
Reference-side flow rate	1.0 gpm
Fouling-side flow rate	5.0 gpm

Results and Discussion

[0024] It was discovered that for a given set of test parameters (bath and cooling water temperatures, flow rates, and heater wattage),

$$(1) \quad Q_r = C \cdot Q_f$$

where Q_r and Q_f stand for heat flux across the reference and fouling sides of the heat transfer surfaces, respectively. C in equation 1 is a constant, which is approximately 1.0. This constant reflects asymmetry introduced during the construction of the deposition sensor and the difference in heat flux sensor sensitivities. This asymmetry can be measured using the initial values of Q_r and Q_f when no deposition is occurring in the fouling side of the apparatus.

[0025] With a constant voltage supplied to the heat cartridge, the total energy dissipating to the reference and fouling side streams is constant,

$$(2) \quad Q_r + Q_f = Q_e$$

where Q_e is the total heat energy provided by the cartridge heater less the energy lost to the environment through the insulation.

[0026] If any deposition occurs on the fouling side, Q_r will no longer equal $C \cdot Q_f$, the difference in heat flux ΔQ_t ,

$$(3) \quad \Delta Q_t = Q_r - C \cdot Q_f$$

is used to detect deposit accumulation.

ΔQ_t and temperature measured by the heat flux sensor during calcium carbonate accumulation and removal are shown in Figs. 3 and 4, respectively. Temperatures can also be measured directly by the thin-film heat flux sensors. The initial decrease in differential heat flux ΔQ_t (between approximately 0-50 minutes) indicates that heat transfer resistance decreases on the fouling side during this period. Decrease in heat transfer resistance in the early stage of deposit accumulation has been reported in many laboratory studies (A Rational Approach to Problems of Fouling Deposition, by W. G. Characklis, in Fouling of Heat Exchanger Surfaces, edited by R. W. Bryers, United Engineering Trustees, Inc., 1983) and is primarily attributable to initial turbulence in the system as is well known in the art, and thus can be discounted.

With reference again to Fig.'s 3 and 4, there is illustratively shown the fouling side temperature 300 data, the reference side temperature 310 data, and the differential heat flux 320 data. As shown in Fig. 3, the differential heat flux (ΔQ_t) 320 exhibits a shadow minimum about 720 minutes, or 12 hours, after the onset of calcium contaminant feeding in the system. This shadow minimum indicates the starting point of an upward trend in the slope of the differential heat flux 320. Accordingly, the shadow minimum corresponds to the starting time at which the accumulation of deposition in the system begins to clearly affect heat transfer resistance across the heat transfer surface. By comparison, the fouling side temperature 300 data does not begin to show a clear upward trend until about 1000

minutes after the start of calcium feeding. In other words, the differential heat flux measurement detects the onset of deposit accumulation in the system approximately 280 minutes sooner than with the traditional temperature based method.

[0027] Fig. 6 compares the trend in the differential heat flux 320 obtained from the current deposition sensor to the U coefficient 510 of the heat exchanger. This figure shows that the early onset of calcium carbonate deposition is detected by the differential heat flux (ΔQ_t) sensor approximately 12 hours after the start of calcium feeding, while the traditional U coefficient measurement, based on temperature differences, does not provide the same clarity.

[0028] In Fig. 7, changes in both heat flux ΔQ_t 700 and heater side temperature T_w 710 during the deposit removal stage are presented relative to their standard deviations. It is clear that the differential heat flux ΔQ_t 700 is much more sensitive than the temperature T_w 710 to changes in the cleanliness of the heat transfer surface.

[0029] Based on an equivalent electric circuit analysis and assuming that initial heat transfer resistances (R_o) on both sides are equal before any deposit accumulation, an approximate relationship can be derived:

$$(5) \quad \delta R/R_o \approx \Delta Q_t/Q_f \approx 2 \Delta Q_t/Q_e$$

where δR stands for the change in heat transfer resistance caused by deposition on the fouling side.

[0030] Note that it is the total heat flux Q_e that is held constant, not Q_f or Q_r . Variations in Q_f can reflect process variations while variation in Q_e are mainly caused by variation in the cartridge heater wattage. From equation 5, it is clear that the differential heat flux ΔQ_t can be used to indicate the early onset of deposition and to quantify the deposit accumulation.

[0031] The mean absolute deviation (MAD) of the 10-minute moving average of differential heat flux collected during CaCO_3 accumulation (Fig. 3) is $7.5 \text{ Btu} \cdot \text{hr}^{-1} \cdot \text{ft}^{-2}$ while the MAD of the baseline data shown in Fig. 1 is $7.0 \text{ Btu} \cdot \text{hr}^{-1} \cdot \text{ft}^{-2}$. The detection limit for the current deposition sensor was estimated at

0.23% ($2*3*MAD/20000*100\%$) using equation 5 and a known Q_e value of 20000 Btu • hr⁻¹ • ft². This suggests that the current deposition sensor is capable of measuring a 0.23% change in heat transfer resistance with a 95% confidence level.

[0032] While specific embodiments of the present invention have been described, it will be apparent to those skilled in the art that various modifications thereto can be made without departing from the spirit and scope of the invention as defined in the following claims.

[0033] What is claimed is: